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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Jean-Michel Daga et al. PATENT APPLICATION
Serial No.: 10/810,033 Group Art Unit: 2816
Filed: March 26, 2004 Examiner:
For: HIGH EFFICIENCY, LOW COST, CHARGE PUMP CIRCUIT

Supplemental Information Disclosure Statement

Hon. Commissioner for Patents
Alexandria, VA 22313

Sir:

The following information is submitted in compliance with Applicants' duty of disclosure under 37 CFR § 1.56. A copy of the reference is enclosed.

Other Reference

Hongchin Lin et al., "New Four-Phase Generation Circuits for Low-Voltage Charge Pumps", IEEE, 2001, pp. 504-507.

CERTIFICATE OF MAILING

I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Asst. Commissioner for Patents, Alexandria, VA 22313

Signed: Sally Azevedo
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Respectfully submitted,

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FORM PTO-1449

Atty. Docket No.
ATM-276Serial No.
10/810,033LIST OF PRIOR ART
CITED BY APPLICANTApplicant:
Jean-Michel Daga et al.Filing Date:
March 26, 2004Group:
2816

U.S. PATENT DOCUMENTS

Examiner Initial*	Document Number	Grant Date	Name	Class	Sub Class	Filing Date
AA						
AB						
AC						
AD						
AE						
AF						
AG						
AH						
AI						
AJ						

FOREIGN PATENT DOCUMENTS

Examiner Initial*	Document Number	Grant Date	Country	Class	Sub Class	Translation Yes No
AK						
AL						

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

AM	Hongchin Lin et al., "New Four-Phase Generation Circuits for Low-Voltage Charge Pumps", IEEE, 2001, pp. 504-507.
AN	
AO	

EXAMINER:

DATE CONSIDERED:

*Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.